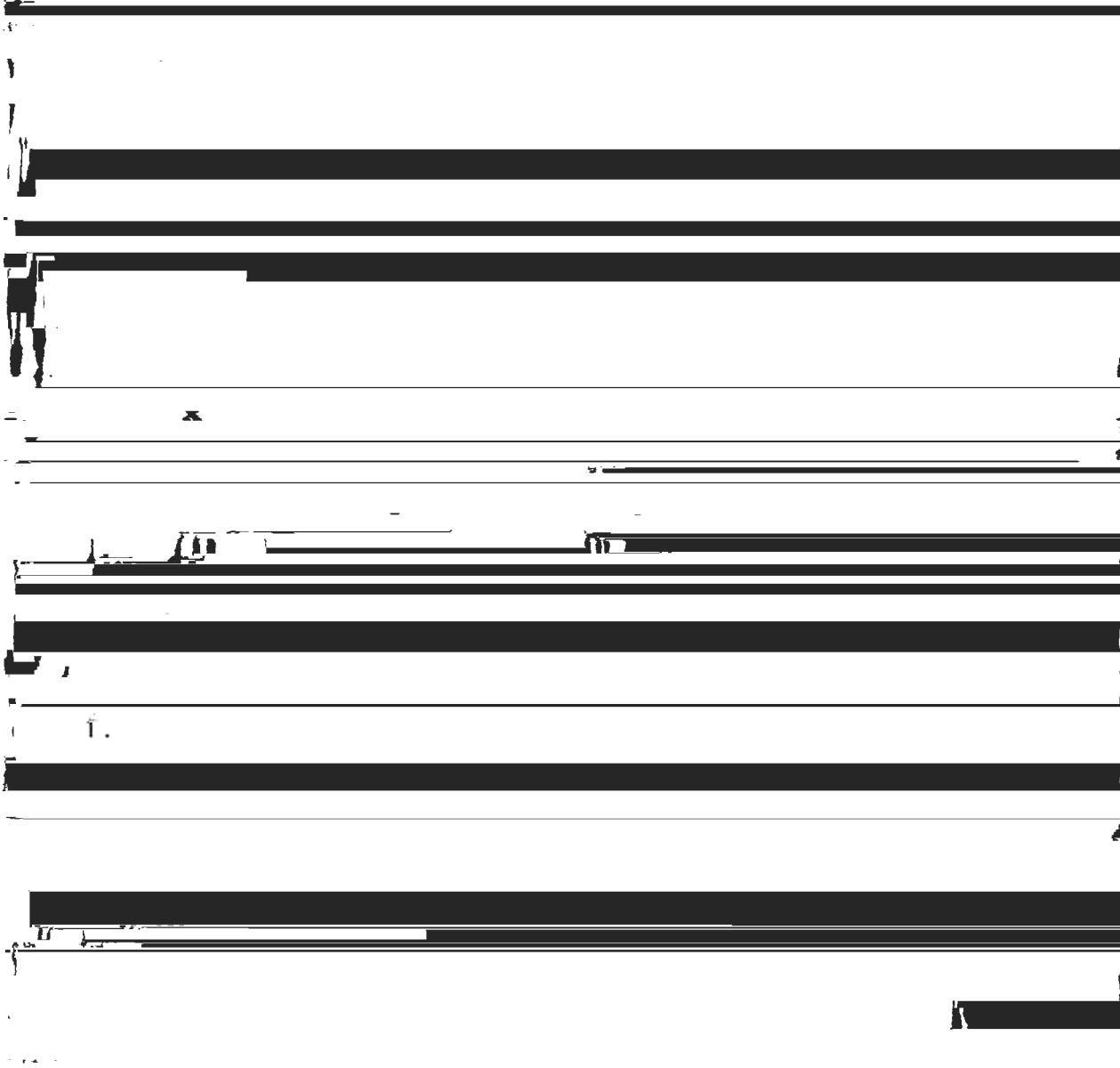


Wavelength

nm



Yuichi NAGASAKI

Osamu MATSUNAGA

Akio KONDO

The value high density ITO target of 00% or more in relative density is denoted by the





power cable of the sputtering source (shown in [redacted])

low resistance because of higher packing density

[redacted]

[redacted]

[redacted]

[redacted]

[redacted]

[redacted]

[redacted]

[redacted]

[redacted]

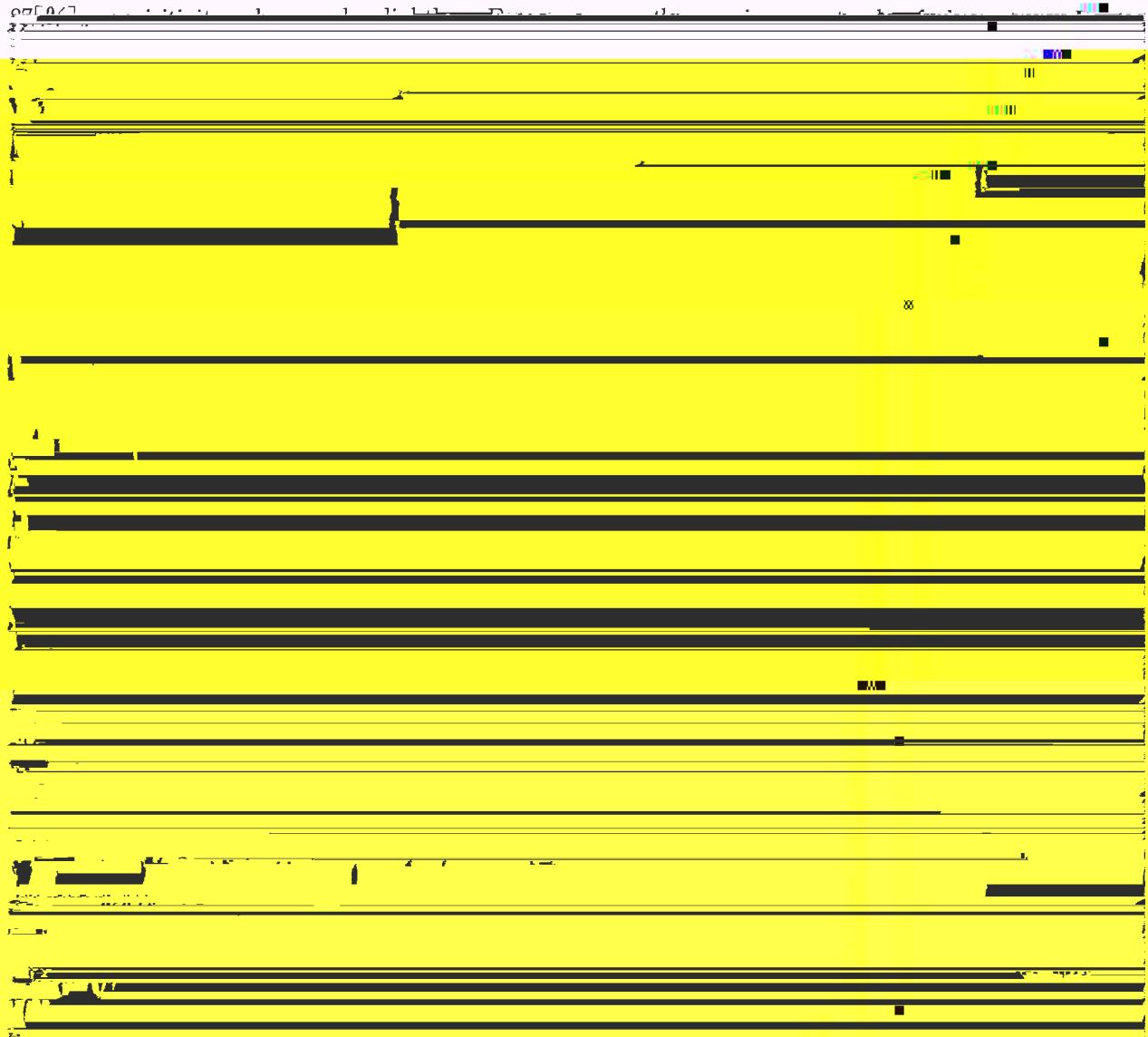


18

Interval of 5000000 Bytes - 0.1 sec (1000)

DATA

W



8

